

Search Notes

Application/Control No.

10/802,162

Examiner

Paulos M. Natnael

Applicant(s)/Patent under
Reexamination

LEE, HWAL RIM

Art Unit

2622

SEARCHED

| Class | Subclass | Date | Examiner |
|-------|-----------------------------|----------|----------|
| 348 | 579,569.7 35,732,72 5 | 8/1/2006 | PMN |
| 455 | 154.1 | 8/2/2006 | PMN |
| | 154.2 | >> | ↓ |
| | 159.1 | >> | |
| | 161.3. | >> | |
| 725 | 38,72 | >> | |
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INTERFERENCE SEARCHED

| Class | Subclass | Date | Examiner |
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**SEARCH NOTES
(INCLUDING SEARCH STRATEGY)**

| | DATE | EXMR |
|------|----------|------|
| EAST | 8/1/2006 | PMN |
| | 8/2/2006 | PMN |
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